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L Number	Hits	Search Text	DB	Time stamp
-	1	("6384461").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/08/20 10:57
-	0	6384461.URPN.	USPAT	2003/02/20 11:40
-	2	("5574292" "5616524").PN.	USPAT	2003/02/20 11:40
-	1219	first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 17:05
-	366	(first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/21 09:05
-	308	((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and (438/\$6 257/\$6)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 17:06
-	133	(((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and (438/\$6 257/\$6)) and ("a" amorphous) near (silicon si)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:21
-	93	mushroom near (shape shaped) near2 electrode	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:24

	2	(first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide))) and (mushroom near (shape shaped) near2 electrode)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:25
	2	((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and 257/458	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:27
	70	((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and (438/\$6 257/\$6) and (source drain "s/d") near2 electrode	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:29
	2	(first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide))) and lateral with leak\$3 with current	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:47
	3	(first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide))) and lateral\$2 with leak\$3 with current	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:49
	161	(first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide))) and leak\$3 with current	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 14:49

	308	((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and (438/\$6 257/\$6)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 17:09
	521	first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)) and (438/\$6 257/\$6) not (((first near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second near2 (dielectric passivation insulating insulation passivating) with ((oxide dioxide di near oxide))) and (first with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide)) and second with ((oxide dioxide di near oxide)))) and (438/\$6 257/\$6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/20 17:14
	72	(dual two) near2 (dielectric passivation insulating insulation passivating) with ((silicon near (oxynitride oxy near nitride) "siO.sub.xN.sub.y" "si O.sub.x N.sub.y" "si O.sub.y N.sub.x" "siO.sub.yN.sub.x") (benzocyclobutene benzo near cyclo near butene benzo near cyclobutene benzocyclo near butene BCB) (polyamide poly near amide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/21 09:11
	6	("4700457" "4985718" "4990463" "5006481" "5262354" "5312512").PN.	USPAT	2003/02/21 09:22
	3	("5232970" "5288989" "5416233").PN.	USPAT	2003/02/21 09:23
	9	("4577395" "4833094" "5026659" "5162248" "5270241" "5275974" "5292679" "5384152" "5604696").PN.	USPAT	2003/02/21 09:23
	2	full near fill near factor near image near array	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/21 09:46
	2	full near fill near factor near image near array	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/21 09:48
	10	fill near factor near imag\$3 near array	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/21 09:49

-	3	("5499207").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT USPAT	2003/08/20 11:40
-	11	5499207.URPN.		2003/08/20 11:40
-	3	("5155573" "5321649" "5382817").PN.		2003/08/20 11:40